

*“Etching induced formation of interfacial FeMn in IrMn/CoFe bilayers”*. O'Donnell D, Hassan S, Du Y, Gauquelin N, Krishnan D, Verbeeck J, Fan R, Steadman P, Bencok P, Dobrynin AN, Journal of physics: D: applied physics **52**, 165002 (2019). <http://doi.org/10.1088/1361-6463/AB03BD>